

Supporting Information

Industrial production of ultra-stable sulfonated graphene quantum dots for Golgi apparatus imaging

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Supporting Figures.

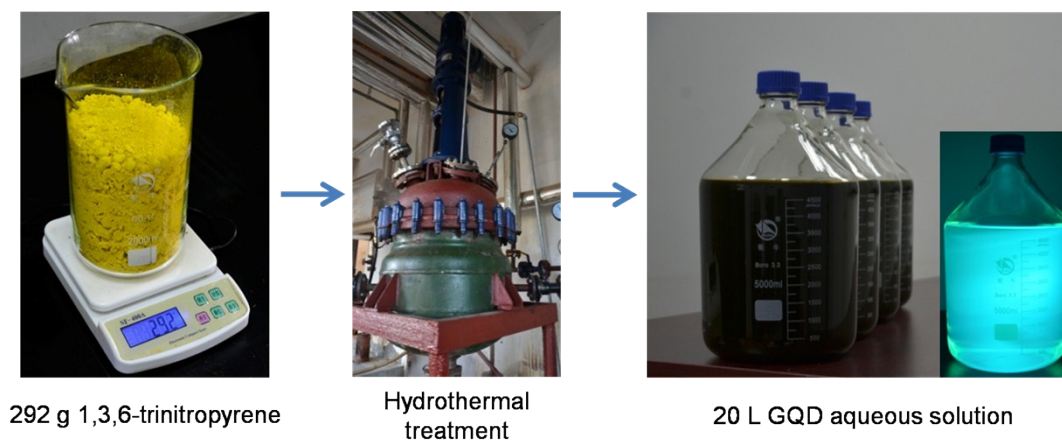


Fig. S1 The preparation procedure for GQDs on an industrial scale.

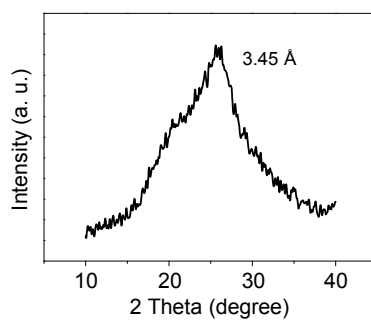


Fig. S2 XRD pattern of sulfonated GQDs.